

METHOD OF USING AN ADHESION PRECURSOR

FIG. 1

METHOD OF USING AN ADHESION PRECURSOR LAYER FOR CHEMICAL VAPOR DEPOSITION (CVD) COPPER DEPOSITION (LOPATIN, ET AL.)
Atty. Docket No.: 039153-0484
Attorney: Paul S. Hunter (608) 258-4292

Sheet 2 of 3

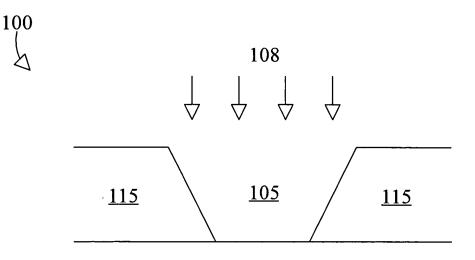


FIG. 2

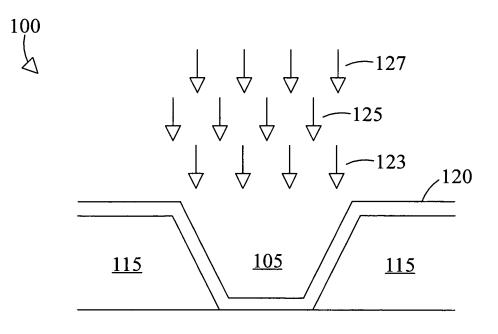


FIG. 3

METHOD OF USING AN ADHESION PRECURSOR LAYER FOR CHEMICAL VAPOR DEPOSITION (CVD) COPPER DEPOSITION (LOPATIN, ET AL.)

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Sheet 3 of 3

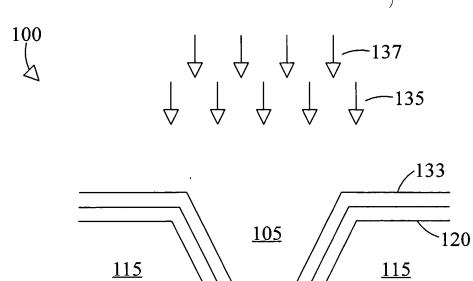


FIG. 4

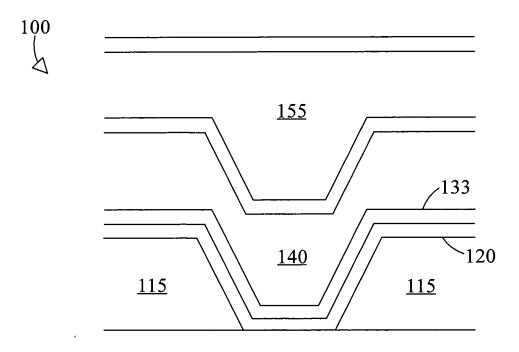


FIG. 5